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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/773,122	10/773,122 02/05/2004		Jan-Der Guo	386998046US	3256
25096	7590	02/04/2005		EXAMINER	
PERKINS	COIE LL	.P	SARKAR, ASOK K		
PATENT-SI P.O. BOX 1			ART UNIT	PAPER NUMBER	
SEATTLE,		11-1247	2829		
				DATE MAILED: 02/04/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

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U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04) Office	Action Summary	Part of Paper No./M	ail Date 0205			
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08  Paper No(s)/Mail Date	Pape	view Summary (PTO-413) r No(s)/Mail Date e of Informal Patent Application (PTO	1-152)			
* See the attached detailed Office action for a lis	* **	not received.				
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).						
2. Certified copies of the priority documer						
1. Certified copies of the priority documer	nts have been received					
a) ☐ All b) ☐ Some * c) ☐ None of:	in priority under 00 0.0	3 110(a)=(a) or (i).				
12) Acknowledgment is made of a claim for foreig	n priority under 35 U.S	C & 119(a)-(d) or (f)				
Priority under 35 U.S.C. § 119						
11) The oath or declaration is objected to by the E	•					
Applicant may not request that any objection to the Replacement drawing sheet(s) including the corre			R 1.121(d)			
10)⊠ The drawing(s) filed on <u>2/5/04</u> is/are: a)⊠ ac						
9) The specification is objected to by the Examir						
Application Papers						
8) Claim(s) are subject to restriction and/	or election requirement	<b>l</b> .				
7) Claim(s) is/are objected to.						
6)⊠ Claim(s) <u>10-17</u> is/are rejected.						
5)⊠ Claim(s) <u>1-9</u> is/are allowed.		•				
4) Claim(s) <u>1-17</u> is/are pending in the applicatio 4a) Of the above claim(s) is/are withdra						
Disposition of Claims	_					
·						
3) Since this application is in condition for allow closed in accordance with the practice under	-		mento io			
	is action is non-final.	matters prosecution as to the	merits is			
1) Responsive to communication(s) filed on <u>05</u>						
Status						
after SIX (6) MONTHS from the mailing date of this communication.  If the period for reply specified above is less than thirty (30) days, a re  If NO period for reply is specified above, the maximum statutory period  Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the maili earned patent term adjustment. See 37 CFR 1.704(b).	ply within the statutory minimum I will apply and will expire SIX (6) te, cause the application to beco	of thirty (30) days will be considered timely MONTHS from the mailing date of this come ABANDONED (35 U.S.C. § 133).	mmunication.			
THE MAILING DATE OF THIS COMMUNICATION  - Extensions of time may be available under the provisions of 37 CFR 1						
Period for Reply  A SHORTENED STATUTORY PERIOD FOR REP	V IS SET TO EXPIRE	3 MONTH(S) FROM				
The MAILING DATE of this communication ap	į.	et with the correspondence add	dress			
•	Asok K. Sarkar	2829				
Office Action Summary	10/773,122 Examiner	GUO ET AL.  Art Unit				
-	Application No.	Applicant(s)				

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#### **DETAILED ACTION**

## Specification

1. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.

The following title is suggested: "Method for forming LED by a substrate removal process".

# Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
  - 1. Determining the scope and contents of the prior art.
  - 2. Ascertaining the differences between the prior art and the claims at issue.
  - Resolving the level of ordinary skill in the pertinent art.
  - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 4. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation

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under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

5. Claims 10 – 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yoo, US 6,818,531.

Regarding claim 10, Yoo teaches a method for forming LED, comprising the steps of:

- forming an LED epitaxial layer 25 or 125 on a provisional substrate 121;
- forming a reflecting layer 24 on said LED epitaxial layer;
- forming a metal layer 22 on said reflecting layer;
- cutting said LED epitaxial layer 25 or 125, said reflecting layer 24, and said metal
   layer 22 to form LED chips with reference to Figs 2 and 3(b),
- removing said provisional substrate 121 to expose surfaces of said LED chips
   with reference to Fig. 3(d) and;
- forming pads 139 on said surfaces of said LED chips with reference to Fig. 3(e)
   and associated descriptions in columns.

Yoo teaches etching the epitaxial layers by dry etching in column 1, lines 65 – 67, but <u>fails</u> to teach etching the epitaxial layer, the reflecting layer and the metal layer by means of photolithography.

However, it would have been obvious to one with ordinary skill in the art at the time of the invention to modify Yoo and etch the epitaxial layer, the reflecting layer and

the metal layer by means of photolithography for the benefit of minimizing the level of stress as suggested by Yoo in column 6, lines 25 – 37.

Regarding claim 11. You teaches the reflecting layer of combination of Ag and Au in column 5, lines 30 – 35.

Regarding claim 16, Yoo teaches the metal layer of Au, Ni, Ag and Al in column 6, lines 15 – 16.

Regarding claims 12 – 15, Yoo fails to teach the methods for depositing the metal layer.

However, it would have been obvious to one with ordinary skill in the art at the time of the invention to modify Yoo and deposit the metal layer by various methods as described in the claims since all these methods are well known deposition methods for metallic layers.

Regarding claim 17, Yoo fails to teach the thickness of the metal layer.

However, given the substantial teaching of Yoo (see column 2, lines 25 - 32), it would have been obvious to one with ordinary skill in the art at the time of the invention to judiciously adjust and control the thickness of the metal layer through routine experimentation and optimization to achieve optimum benefits in terms of heat dissipation (see MPEP 2144.05) and it would not yield any unexpected results.

Note that the specification contains no disclosure of either the critical nature of the claimed processes or any unexpected results arising therefrom. Where patentability is said to be based upon particular chosen methods or upon another variable recited in a claim, the Applicant must show that the chosen methods or variables are critical

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(Woodruff, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir., 1990)). See also In re Aller, Lacey and Hall (10 USPQ 233 – 237).

## Allowable Subject Matter

- 6. Claims 1 9 are allowed.
- 7. The following is an examiner's statement of reasons for allowance:

Claims 1 – 9 recite, inter alia, a method of forming LED comprising the steps of etching the LED epitaxial layer formed on a provisional substrate to form the LED chips by means of photolithography, forming a reflecting layer on the LED chips, forming a metal layer on the reflecting layer, and removing the provisional substrate to expose surfaces of the LED chips. The art of record does not disclose or anticipate the above limitations of forming the metal and the reflecting layers on the etched LED chips in combination with other claim elements nor would it be obvious to modify the art of record so as to form a device including the above limitation.

### Conclusion

- 8. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."
- 9. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Hasegawa, US 4,218,270; Watanabe, US 5,403,916; Fan, US 5,453,405 and Ueda, US 6,657,238 teach forming LED chips by the process of substrate removal.

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10. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Asok K. Sarkar whose telephone number is 571 272

1970. The examiner can normally be reached on Monday - Friday (8 AM- 5 PM).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

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supervisor, William B. Baumeister can be reached on 571 272 1722. The fax phone

number for the organization where this application or proceeding is assigned is 703-

872-9306.

11. Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have guestions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Asok K. Sarkar

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February 2, 2005

Primary Examiner